

U.S. UTILITY Patent Application

PATENT NUMBER and ISSUE DATE

	APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU		EXAMINER	
	10050639	91/15/2002	486		1765	120		
	"APPLICANT	S: Lee Wh	nonchee; l	lu Yongjun;				
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**	FOREIGN AP	PLICATIONS VE	RIFIED:					
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	reign priority claime USC 119 condition		⊒ yes ⊒	⊒ no		ATTORNE	Y DOCKET NO	
/e	rified and Acknowle	edged Examiners's inti	⊒ yes ⊒ als	⊒ no		150.00560	104	
1	TLE: Method a	nd composition fo	r selective	ly etching aga	inst coba	alt silicide		
_						U.S DEPT OF	COMM./PAT.& TM-PTO-436I (F	Rev :2
	F ALLOWANCE							

NOTICE OF ALL	OWANCE MAILED							
			CLA	CLAIMS ALLOWED				
ICCUP FOR		Assistant Examiner	Total Claims		Print Claim for O.G			
Amount Due Date Paid		_	DRAWING					
Allount Due	Date Paid		Sheets Drwg.	Figs.Drwg.	Print Fig.			
- <u>- </u>		Primary Examiner						
TERMINAL		PREPARED FOR ISSUE	Application Examiner					
7 1 6,074,960	DISCLAMER	WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.						
			(CRF)		CD-ROM Inside flap)			